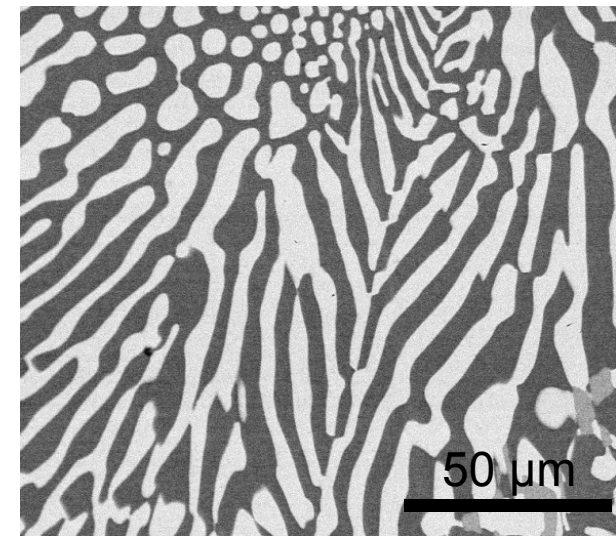


# Beyond Ni-base Superalloys: Refractory Metal Silicides for Ultrahigh Temperature Structural Applications

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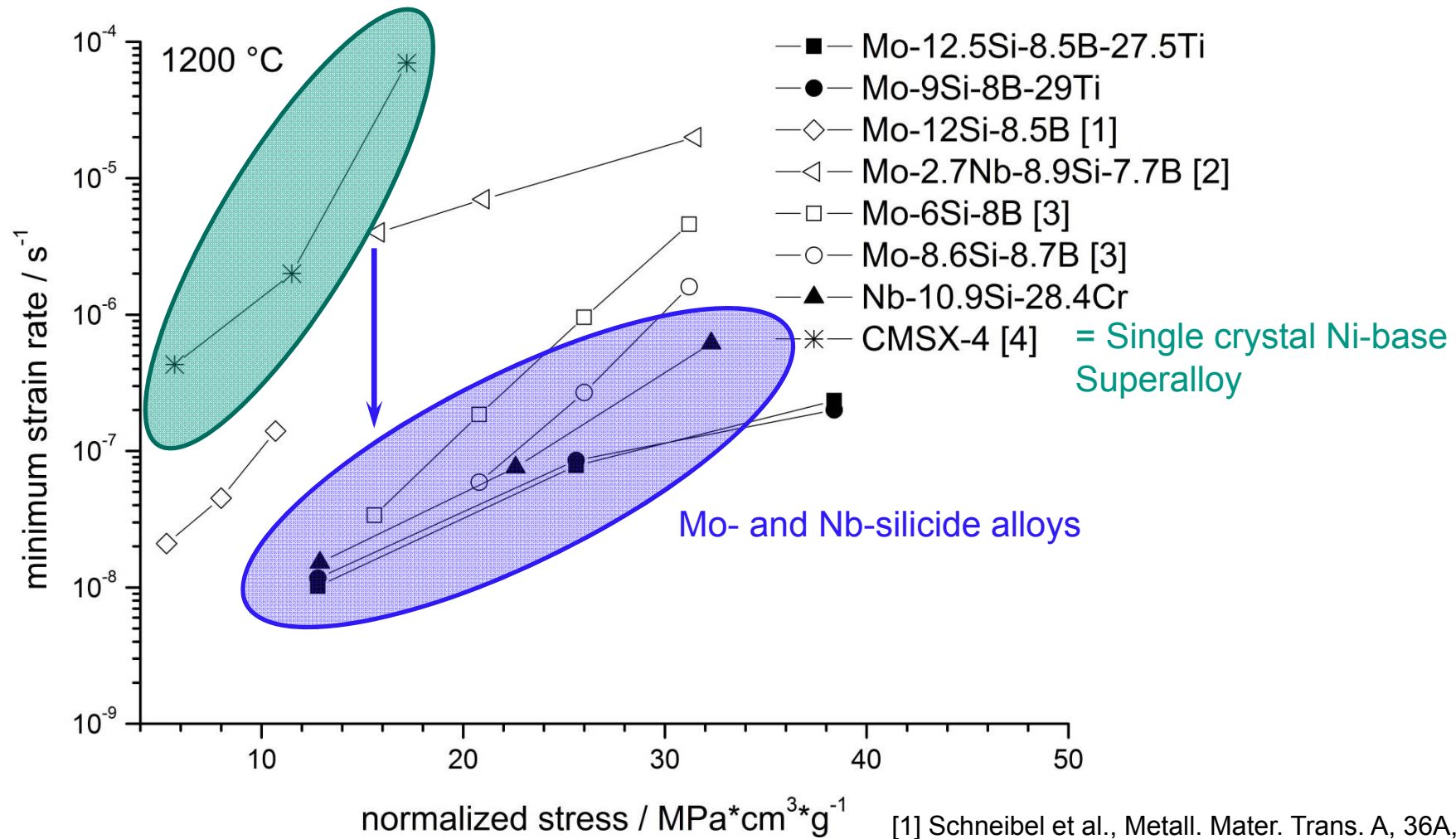


[http://ec.europa.eu/research/transport/projects/items/ultmat\\_en.htm](http://ec.europa.eu/research/transport/projects/items/ultmat_en.htm)

# Outline

- Motivation for novel RM based high temperature alloys
  - Main Advantage: High Melting Points beyond 2000°C
  - Main (Scientific) Issues: Creep, Oxidation, Density
  - Further Issues: Fatigue, Fracture Toughness, Crack Propagation, Manufacturing, ...tbc
- Case study 1: Mo-Si-B(-Ti) alloys
- Case study 2: Nb-Si(-Cr-V) eutectics
- Conclusions
- Acknowledgements

# Refractory metal silicides: creep resistance potential

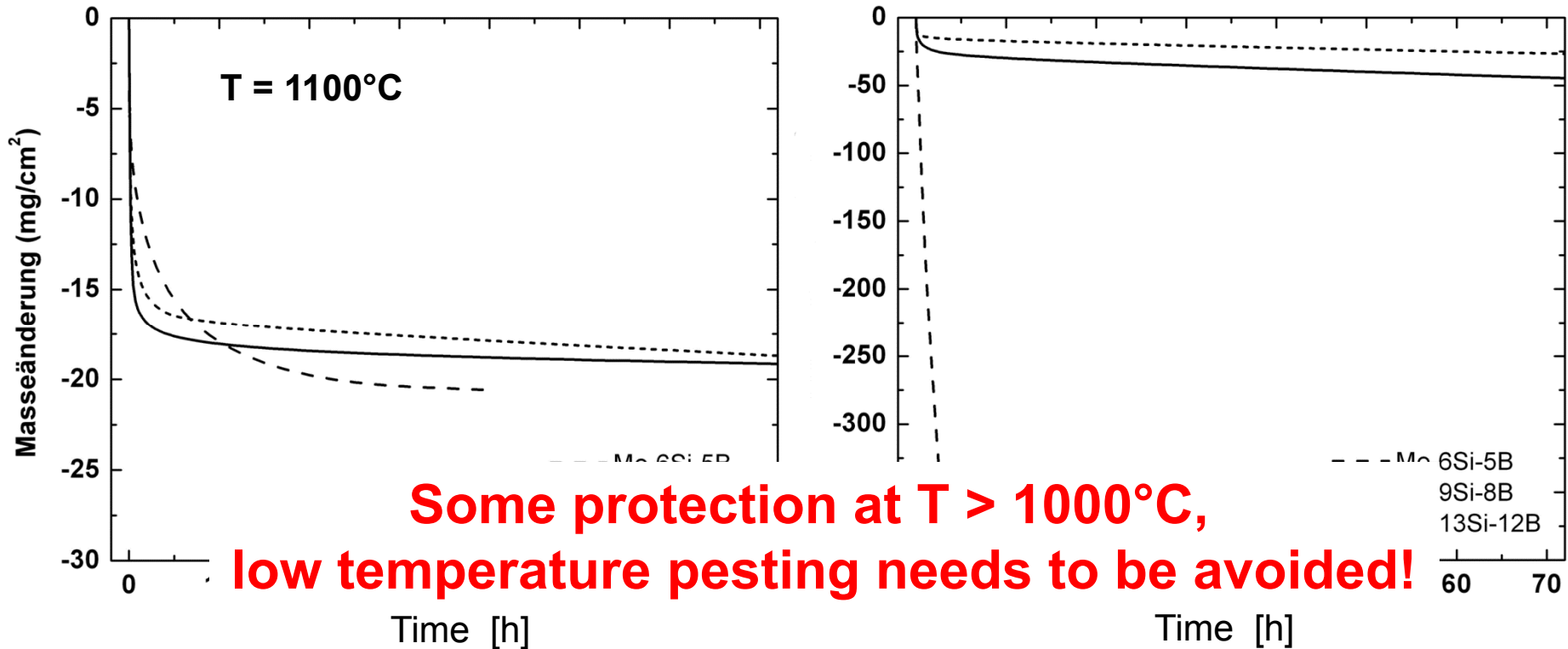


[1] Schneibel et al., Metall. Mater. Trans. A, 36A, 2005  
 [2] Jèhanno et al., Mater. Sci. Eng. A, 463, 2007  
 [3] Jain and Kumar, Acta Mater., 58, 2010  
 [4] Heilmaier et al., JOM 61 (7), 2009

# Outline

- Motivation on high temperature alloys
  - Main (Scientific) Issues: Creep, Oxidation, Density
    - Outstanding creep resistance
    - **What about oxidation resistance and density?**

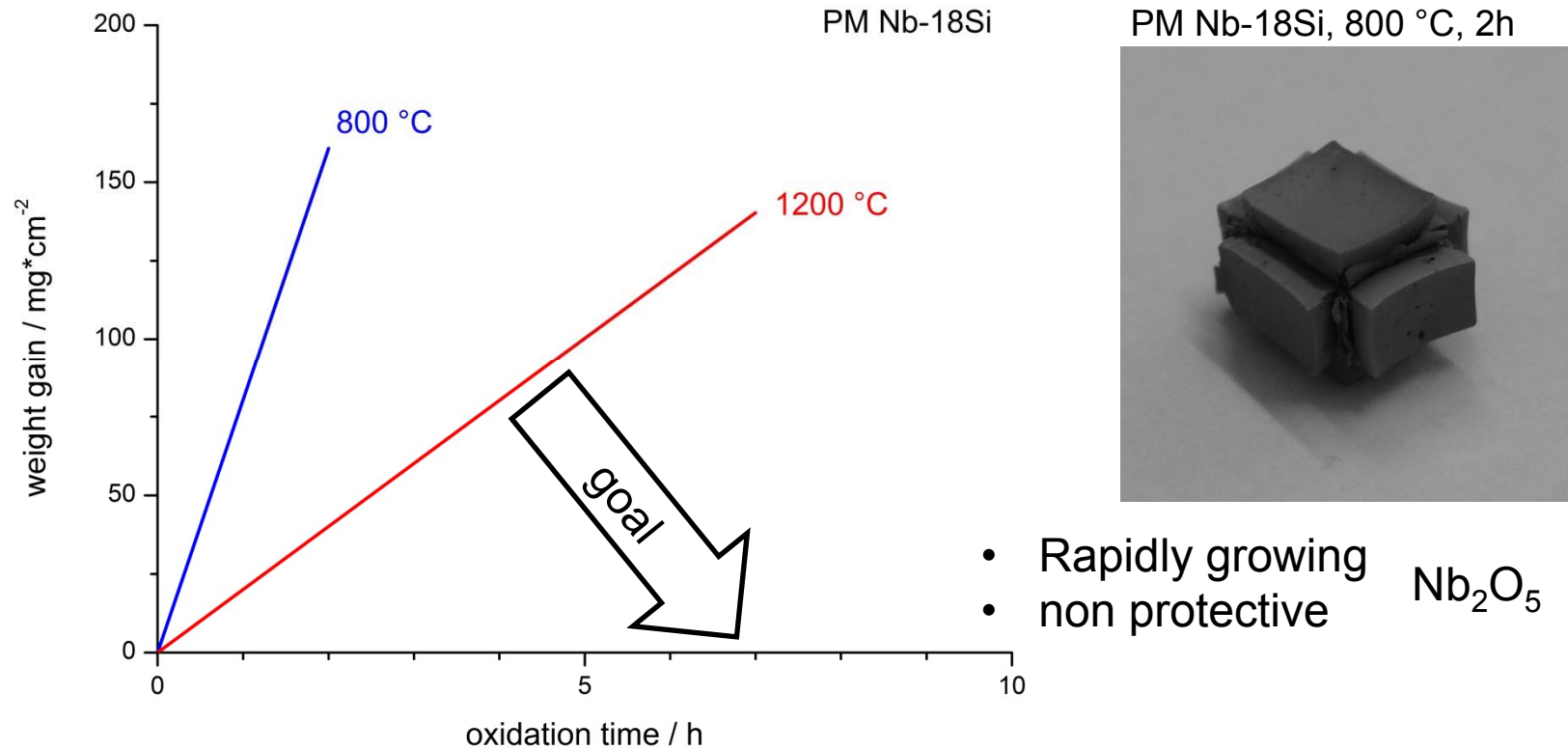
# The ternary system Mo-Si-B: oxidation in air



- Initial weight loss due to MoO<sub>3</sub> sublimation („pestring“), then
- Protection due to formation of Borosilicate glass layer
- dependent on (i) amount of intermetallics and (ii) microstructural fineness

# The Binary Nb-Si System

→ Isothermal high temperature oxidation: **linear weight gain, no protection**



Addition of alloying elements necessary - two alloying concepts:

- Chromium addition
- Vanadium addition

# Case study 1: The Mo-Si-B(-Ti) Alloy System

# Background: Mo-Si-B ternary phase diagram

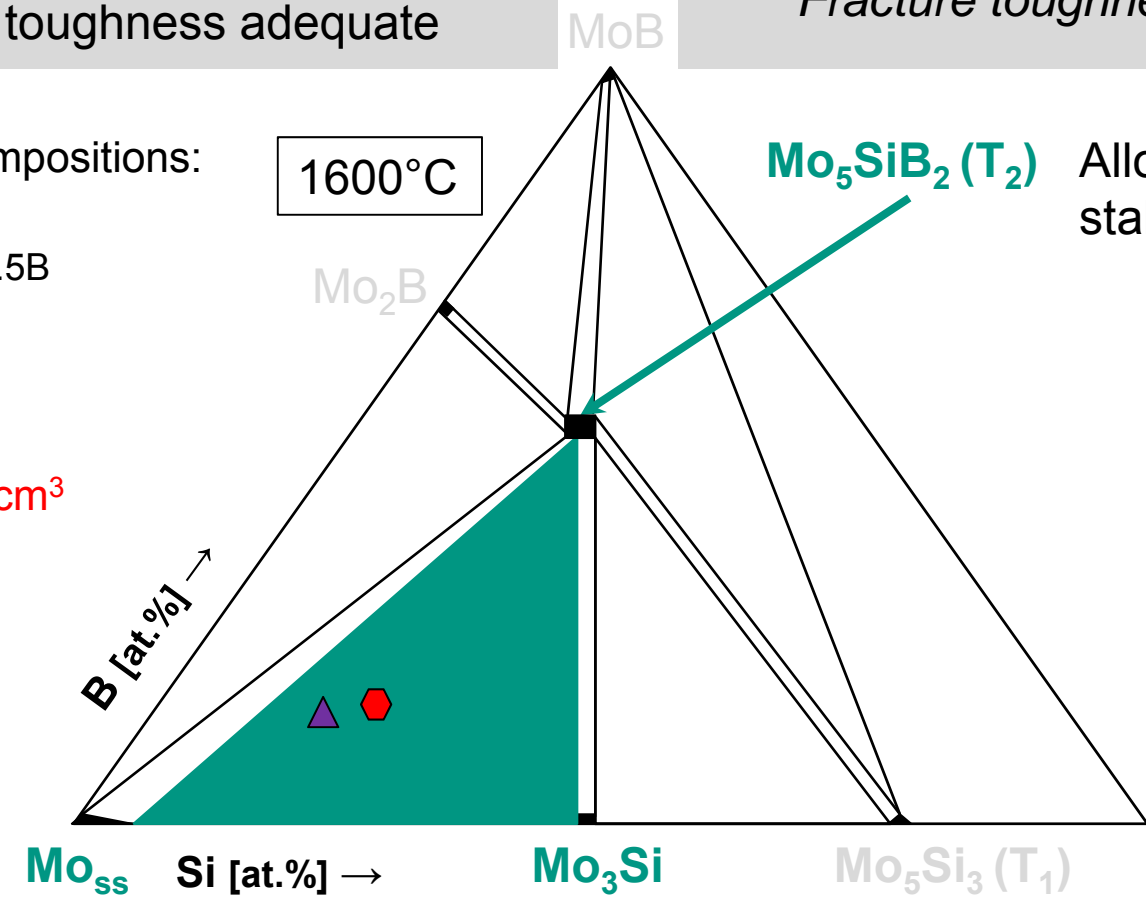
**Mo<sub>ss</sub> + Mo<sub>3</sub>Si + T<sub>2</sub>**  
 Oxidation / Creep resistance high  
 Fracture toughness adequate

**Optimal Mo<sub>ss</sub> + T<sub>1</sub> + T<sub>2</sub>**  
 Oxidation / Creep resistance very high  
 Fracture toughness adequate

Typical alloy compositions:

- ◈ Mo-12.5Si-8.5B
- ▲ Mo-9Si-8B

T<sub>m</sub> ≥ 2000°C  
 Density ≈ 9.5 g/cm<sup>3</sup>



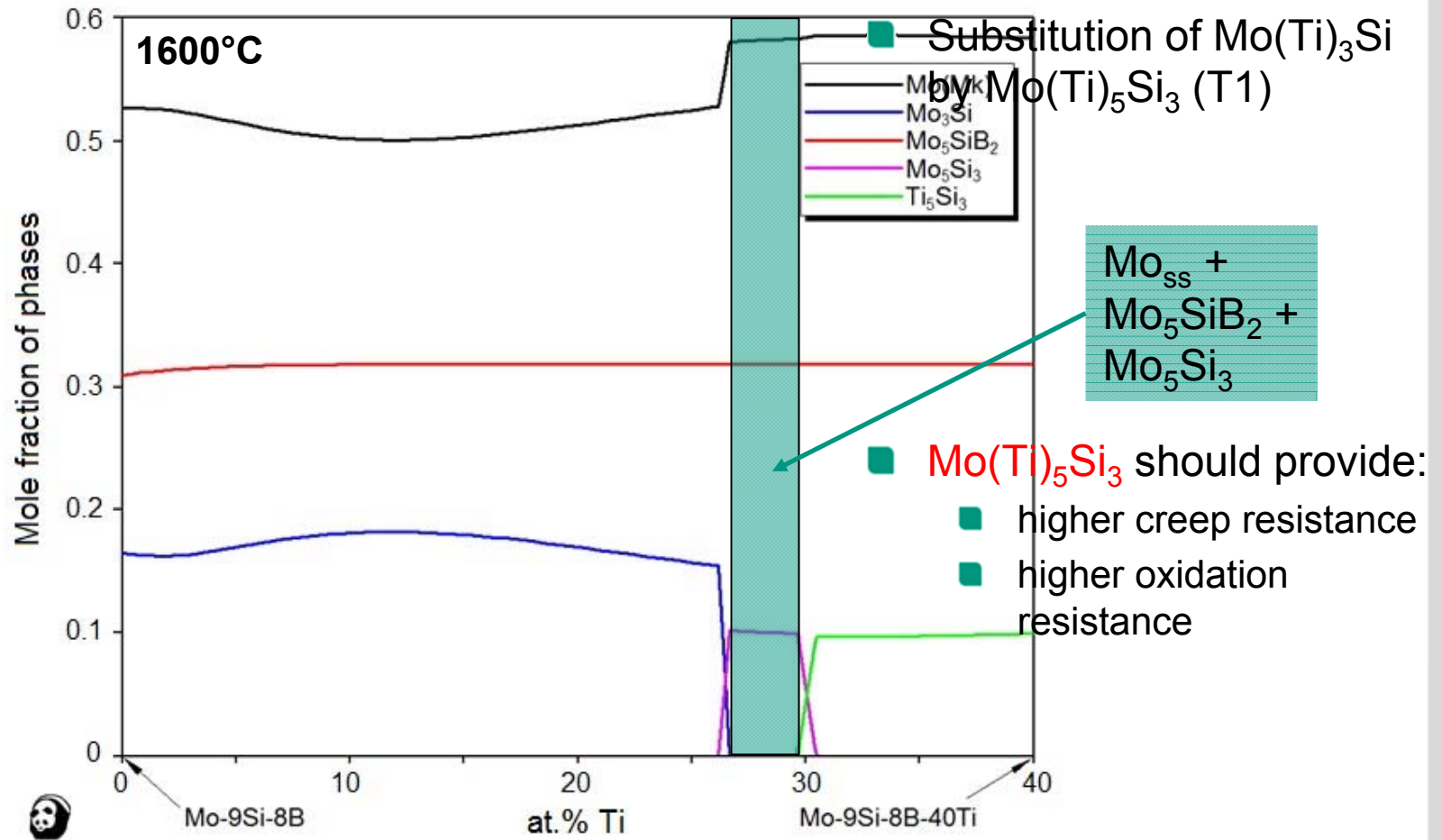
Alloying elements for stabilising T<sub>1</sub>:

- W, Ta (ρ↑)
- Nb (Ox. ↓)
- Ti (ρ ↓)

Isothermal section, schematically after Nunes&Perepezko 1997

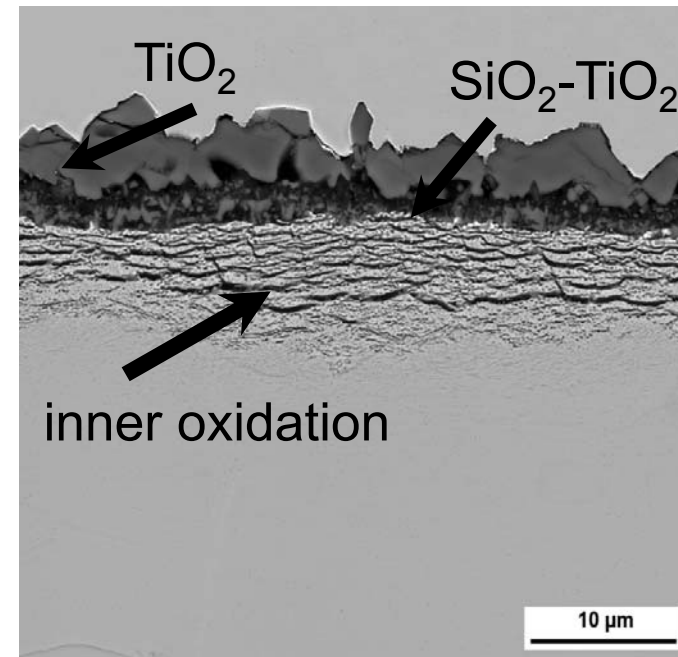
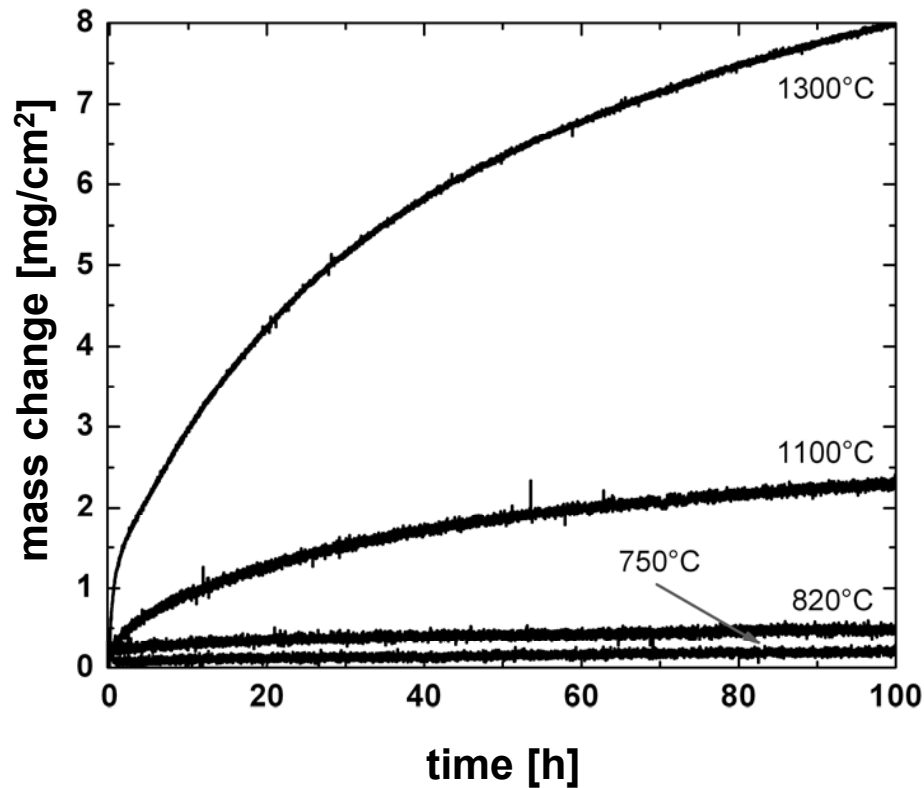


# Why Titanium Alloying in Mo-Si-B Alloys?



# Oxidation resistance of **monolithic $\text{Mo}(\text{Ti})_5\text{Si}_3$** (= Mo-37Si-40Ti)

- Arc-melted and heat treated 1600°C/100h, oxidation in air



SEM (BSE) micrograph

Burk et al., Scripta Mater., 66, 2012.

- weight gain (indicating full protection) even in the pesting regime due to
- formation of a duplex oxide layer with  **$\text{SiO}_2$  matrix**

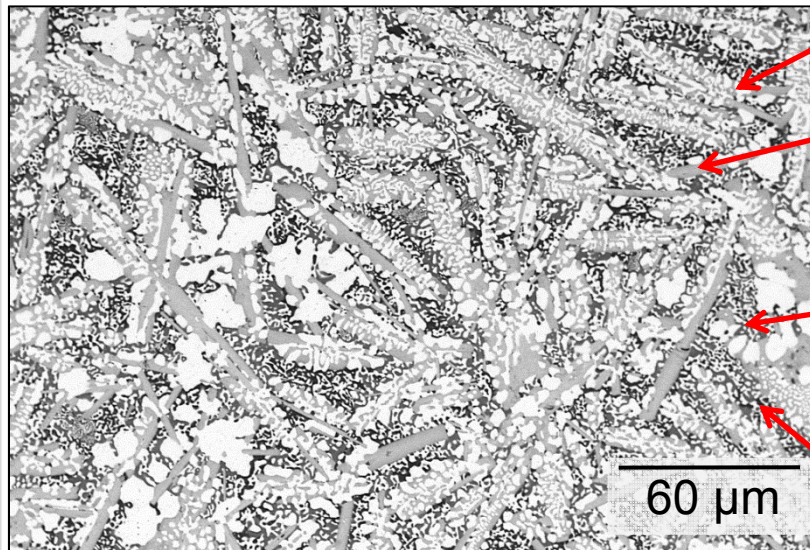
# Multiphase Mo-Si-B-Ti Alloys

- Alloys were arc-melted and homogenized at 1500°C/20h
- Reduction in density to values < 8 g/cm<sup>3</sup>

## Microstructure of Alloys

**Mo-12.5Si-8.5B-27.5Ti [at.%]**

$\rho = 7.7 \text{ g/cm}^3$



Mo<sub>ss</sub>  
(bright)

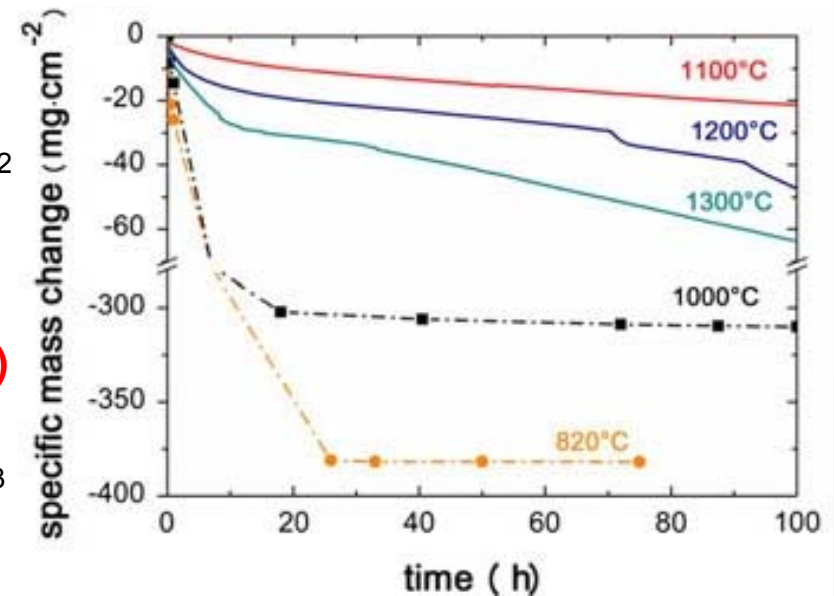
Mo(Ti)<sub>5</sub>SiB<sub>2</sub>  
(gray)

Mo(Ti)<sub>5</sub>Si<sub>3</sub>  
(dark gray)

Ti(Mo)<sub>5</sub>Si<sub>3</sub>  
(dark)

## Oxidation in Air

Still low temperature pesting, no continuous SiO<sub>2</sub> scale formed!



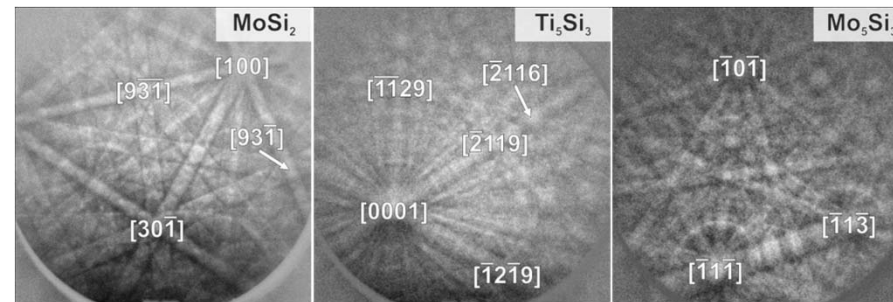
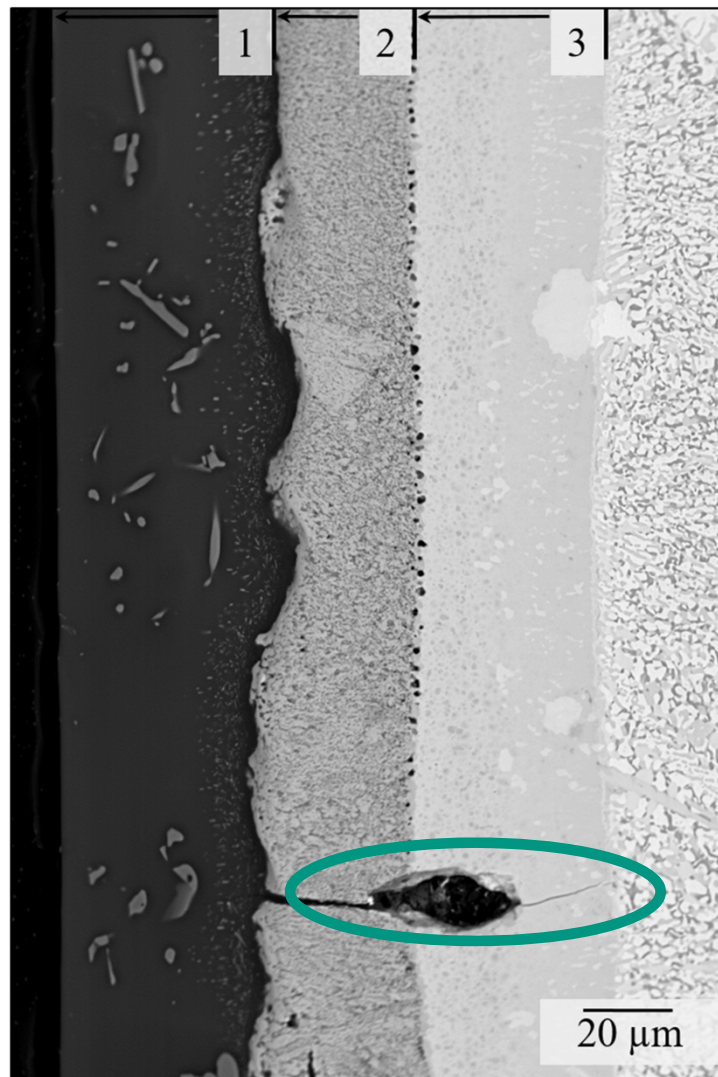
# Si+B pack cementation on Mo-Si-B-Ti alloy (see e.g. Perepezko, Annu. Rev. Mater. Res. 2015)

- Substrate material Mo-12,5Si-8,5B-27,5Ti homogenized at 1600 °C for 100 h
- Pack-cementation:
  - 70 wt.% Al<sub>2</sub>O<sub>3</sub> + 25 wt.% Si+B + 5 wt.% NaF
  - Co-deposition of Si and B at 1000°C for 40 h
  - Conditioning at 1400°C for 10 h

Test parameters:

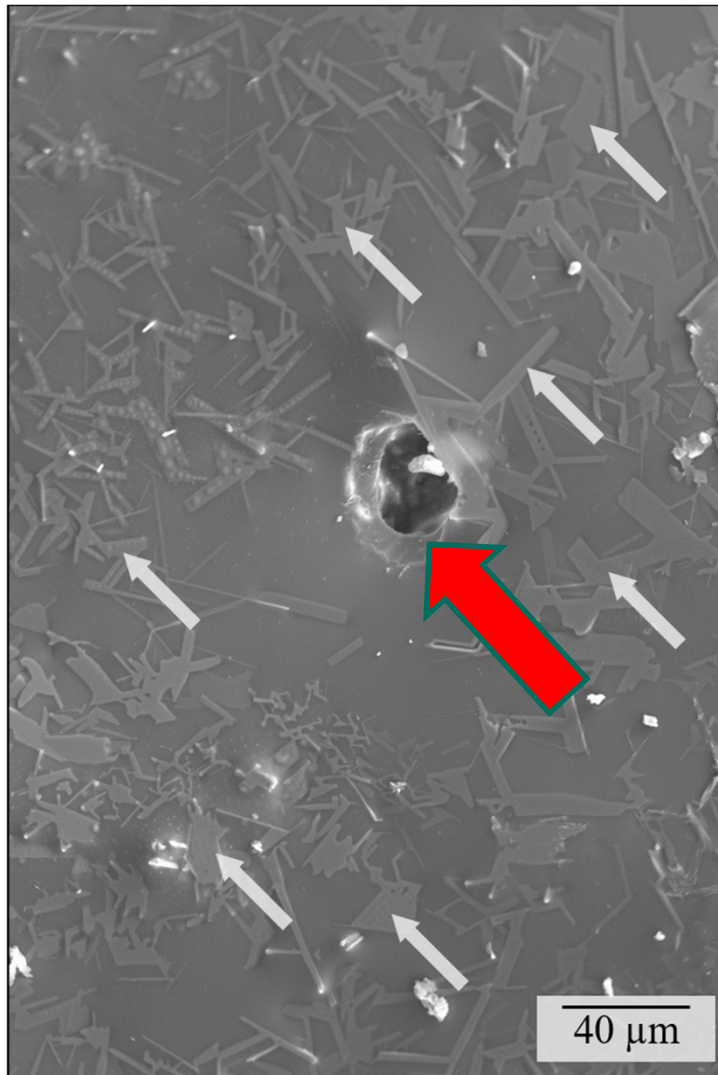
Temperature in °C	Oxidation Mode	Time sample A in h	Time sample B in h	Time sample C in h
800	Thermal cycling	500	1000	1000
1100	Isothermal	100	100	
	Thermal cycling	250	500	500
1200	Isothermal	100	100	
	Thermal cycling	250	500	500

# Layer Arrangement after Conditioning



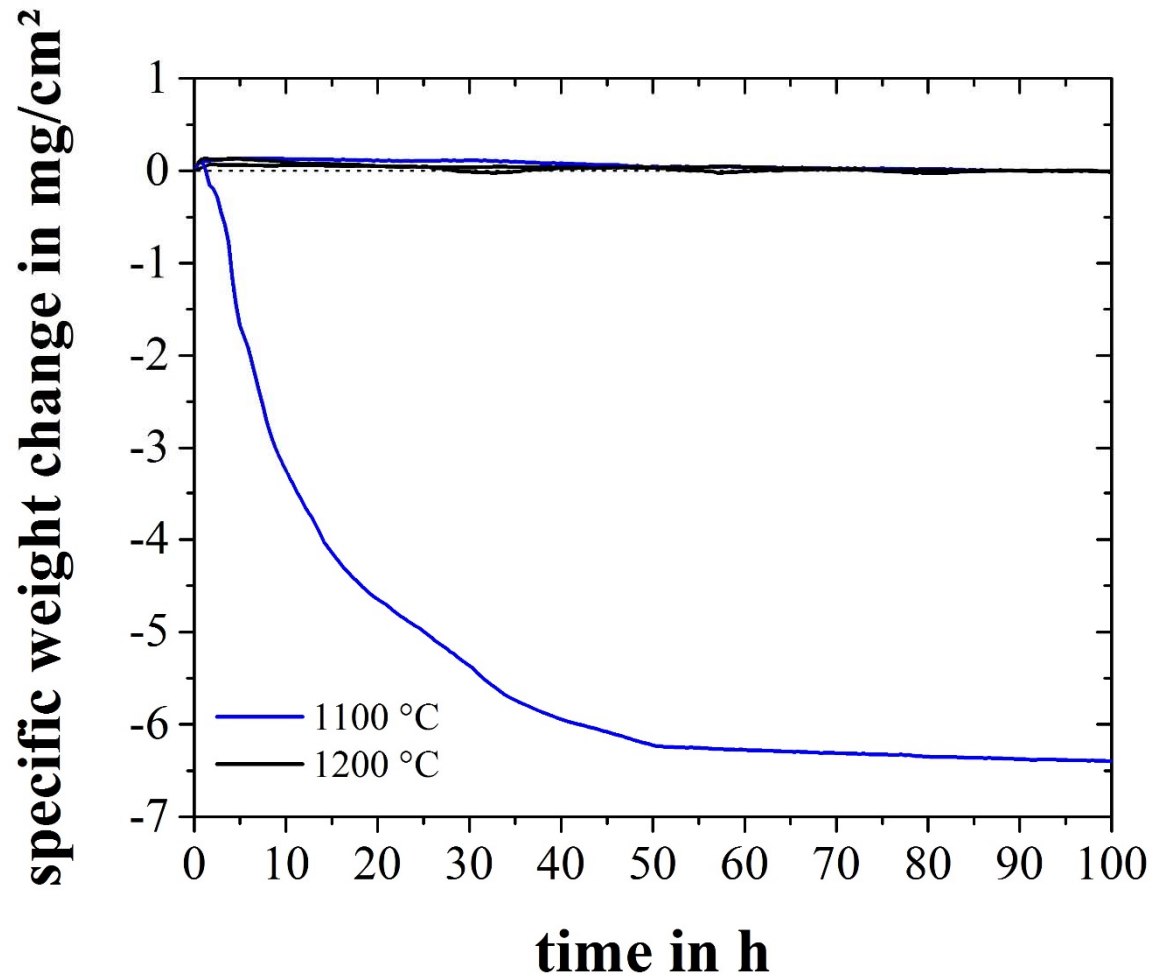
- Layer consists of:
  - 1) Borosilicate with  $\text{Al}_2\text{O}_3$  and  $\text{TiO}_2$  particles
  - 2)  $\text{MoSi}_2$  with probably MoB particles
  - 3)  $\text{Ti}_5\text{Si}_3$  layer with  $\text{MoSi}_2$  and  $\text{Mo}_5\text{Si}_3$  particles
- Cracks and pores filled by Borosilicate

# Layer Surface after Conditioning



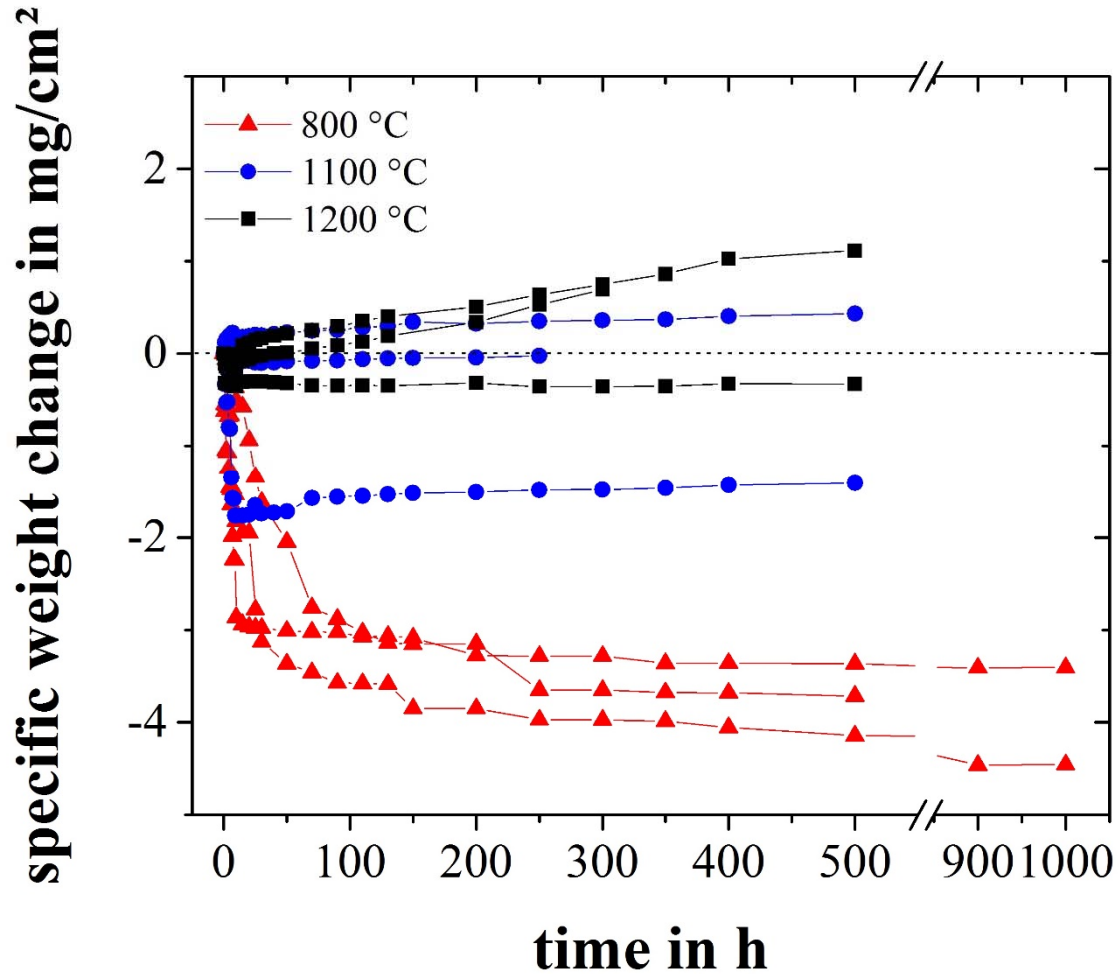
- TiO<sub>2</sub> particles in plate-like shape on borosilicate layer (marked by white arrows)
- Some cavities found as surface defects (red arrow)

# Isothermal Oxidation (TGA)



- 1100 °C initial weight loss due to (random) appearance of surface defects but passivation after 50 h
- 1200 °C no weight change

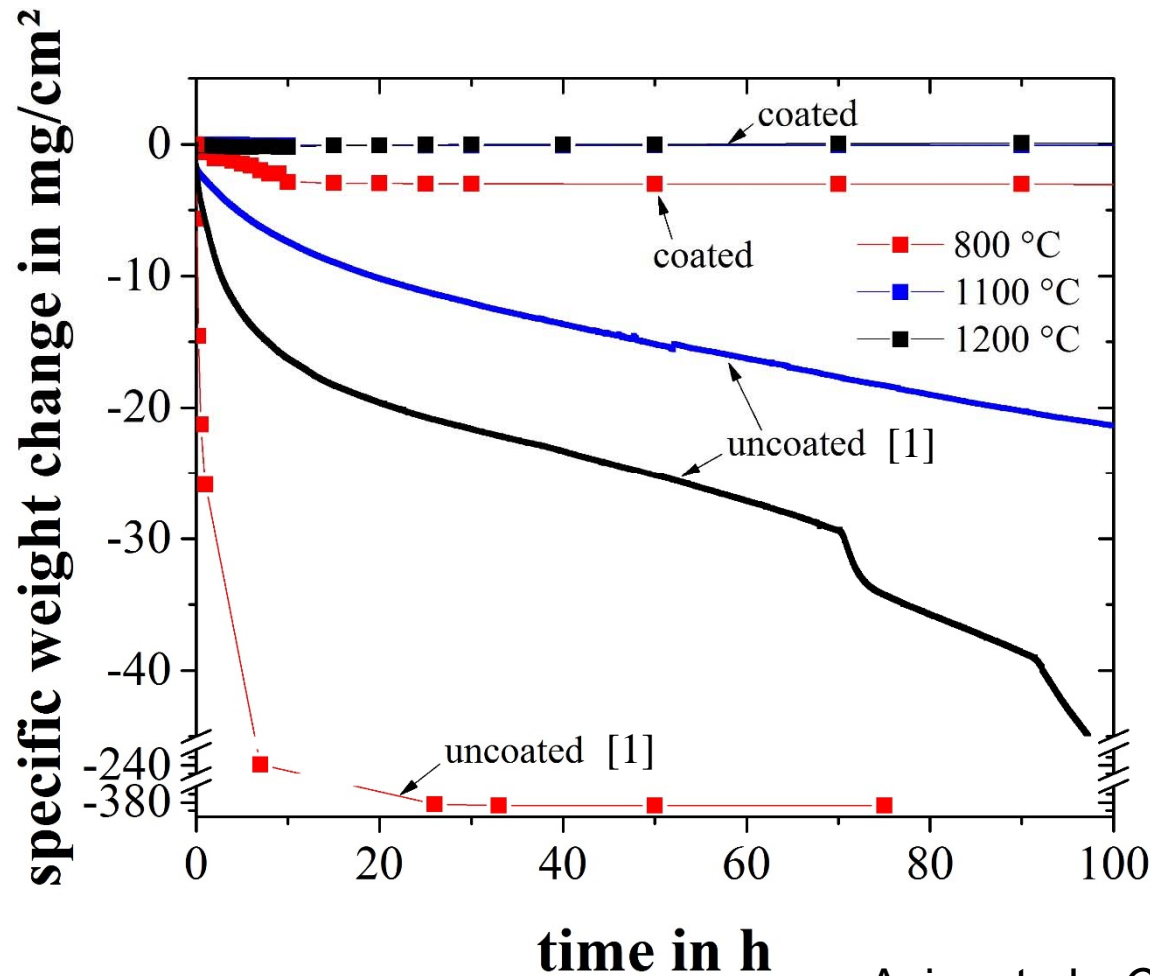
# Cyclic Oxidation



- 800 °C initial small weight loss due to small surface defects but passivation after 100 h
- 1100 and 1200 °C weight gain
- Very little weight change up to 1000 h



# Comparison with uncoated Mo-12.5Si-8.5B-27.5Ti

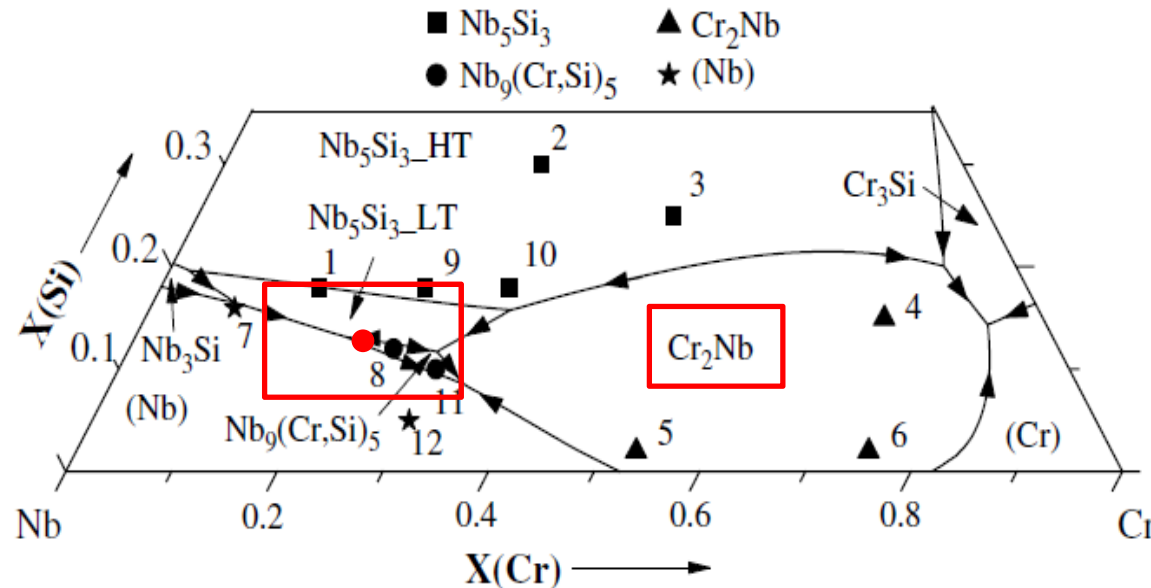


- Weight change at 1100 and 1200 °C negligible compared to uncoated alloy
- Uncoated alloy at 800 °C consumed after 20 h

Azim et al., *Oxidation of Metals* (2013)

# Case Study 2: Nb-Si-Cr(-V) eutectics

# Ternary Eutectic in Nb-Si-Cr



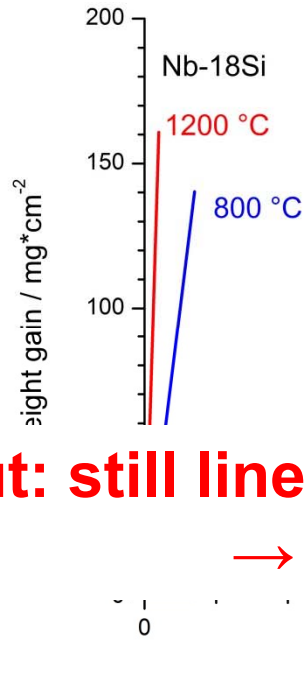
Partial liquidus projection of the system Nb-Si-Cr [Bewlay et al, [2009]

→ Nb-Si-Cr system shows ternary eutectic consisting of  $(\text{Nb})_{\text{SS}}$ ,  $\text{Nb}_9\text{SiCr}_4$  &  $\text{Cr}_2\text{Nb}$ : desirable for directional solidification (DS)

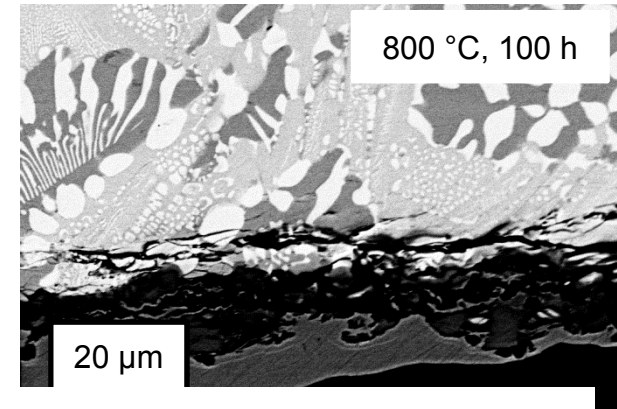
→  $\text{Cr}_2\text{Nb}$  enables the formation of the better protective oxide  $\text{NbCrO}_4$

**Density 7.7 g/cm<sup>3</sup>!**

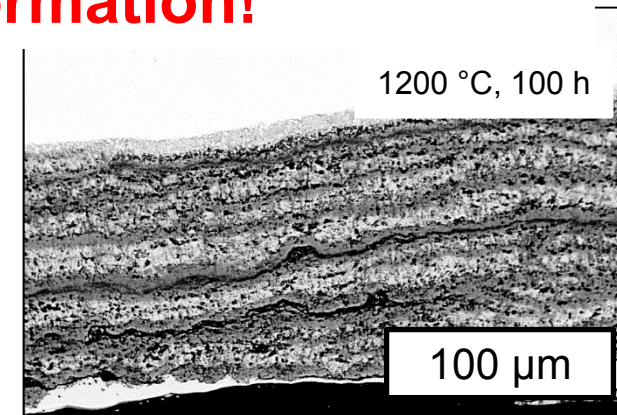
# Isothermal oxidation of ternary eutectics



Nb-8.66Si-33.15Cr

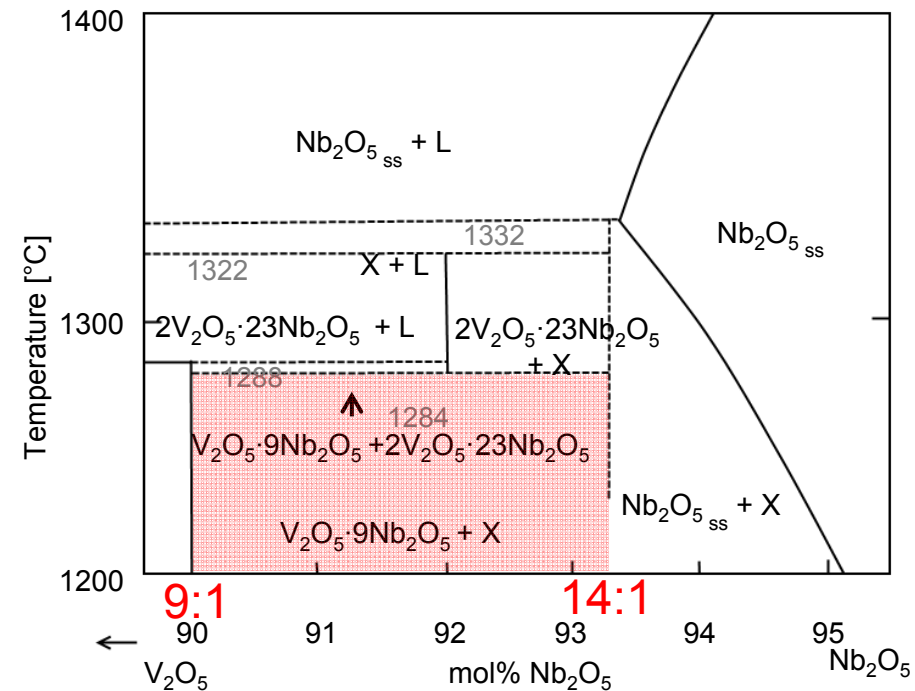
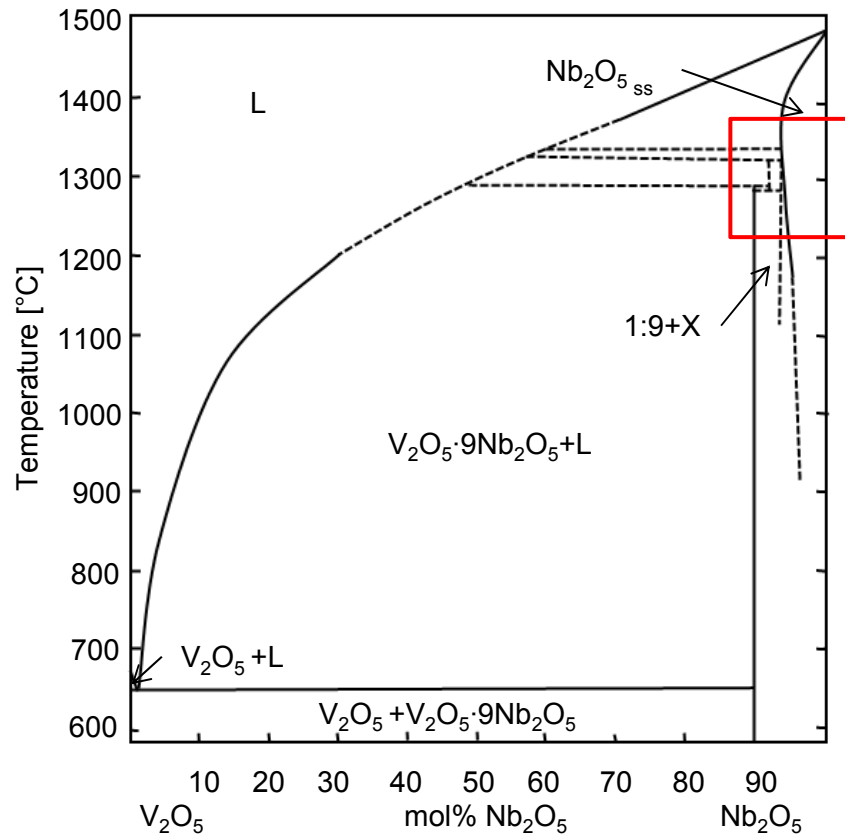


**But: still linear oxidation, spallation needs to be avoided  
→ no protection by scale formation!**



alloy composition	k <sub>1</sub> / mg*cm <sup>-2</sup> *h <sup>-1</sup>		phase fraction Cr <sub>2</sub> Nb / %
	800 °C	1200 °C	
Nb-18Si	80.4	20.0	-
Nb-8.66Si-33.15Cr	0.018	0.18	32.7 ± 7.6
Nb-10.9Si-28.4Cr	0.054	0.21	17.7 ± 4.9

# Influence of Vanadium on oxidation resistance of Nb-Si-Cr eutectics



Binary Nb-V system:

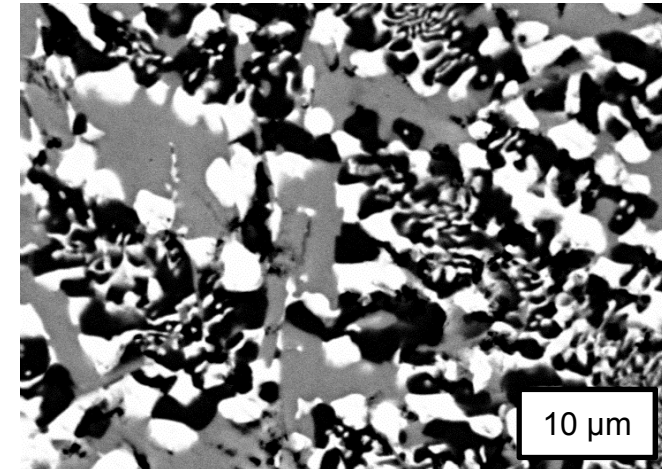
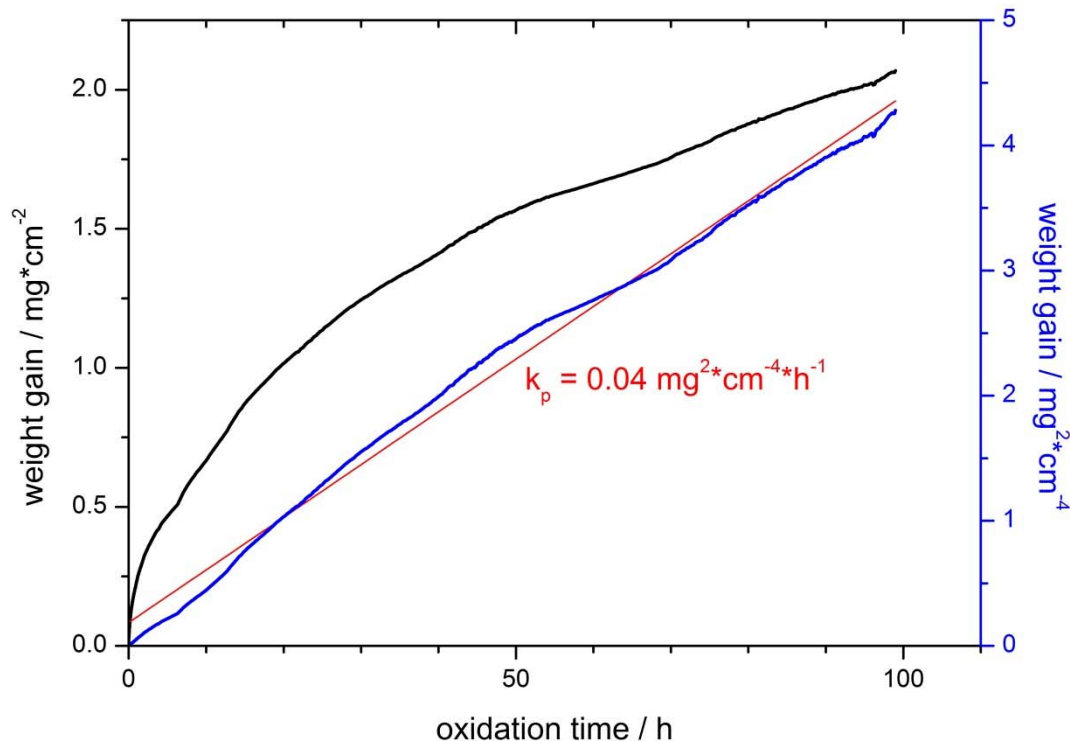
→ formation of the dense, adherent oxide  $V_2O_5 \cdot 9Nb_2O_5$  in the designated compositional range

J.L. Waring, R.S. Roth, Phase equilibria in the system Vanadium Oxide-Niobium Oxide, J. of Research of the National Bureau of Standards – A. Physics and Chemistry Vol. 69A, No.2 (1963), p. 119 - 129

# Combined effect of V and Cr on oxidation resistance

→ Nb10.9Si28.4Cr4.86V (Nb:V ratio = 11.5:1)

Nb10.9Si28.4Cr4.86V, 800 °C



phase	areal fraction / %
(Nb)	18.8 ± 1.9 (14.6)
Cr <sub>2</sub> Nb	20.8 ± 1.6 (17.7)
Nb <sub>9</sub> SiCr <sub>4</sub>	60.4 ± 3.2 (67.7)

V evenly distributed in all three phases (EDS)

→ weight gain following a parabolic rate law!

→ scale formation needs to be clarified, but **no spallation!**

# Conclusions

1. Creep Resistance in both alloy systems is found superior to Ni-base superalloys even without utilizing processes such as DS or SX
2. Weight/density can be favorably low in both alloy systems, i.e.  $< 8 \text{ g/cm}^3$  without sacrificing other properties
3. Oxidation resistance:
  - Nb-silicides:
    - Alloying with Cr decreases oxidation rate constant, but does not suppress spallation and oxide cracking
    - V suppresses spallation
    - A combination of Cr and V leads to parabolic oxidation rate constant at  $800^\circ\text{C}$ , indicates sufficient protection
  - Mo-silicides:
    - Peeling at intermediate T cannot be avoided due to slow kinetics of borosilicate glass formation
    - Pack cementation leads to virtually full protection with very low weight changes and exhibits self-healing capacity

# Acknowledgements

- financial funding by DFG (Deutsche Forschungsgemeinschaft)
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DFG

Thank you very much for your attention!